

## REVIEW

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# Recent progress and future prospects of atomic layer deposition to prepare/modify solid-state electrolytes and interfaces between electrodes for next-generation lithium batteries†

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Lithium ion batteries (LIBs) are encouraging electrochemical devices with remarkable properties including a high energy/power density, fast charging capability, and low self-discharge rate. Further increase in energy density as well as safe usage is needed for next-generation LIBs in electric transportation vehicles. Solid-state electrolytes (SSEs) are very promising for high-performance LIBs since they enable improved safety along with increased energy density compared to flammable liquid organic electrolytes. However, utilizing SSEs with a Li metal anode is very challenging due to the possibility of undesired side reactions and the formation of an unstable solid-electrolyte interphase. Therefore, it is critical to enhance the stability of SSEs against the Li anode. One feasible approach is to form a thin and conductive interlayer between the Li anode and solid-state electrolyte. Atomic layer deposition (ALD) is a unique technique for conformal coating of complex 3D structures with finely controlled film thickness (at the atomic scale). ALD coating on the surface of SSEs can be adopted for engineering solid-electrolyte interfaces with desired attributes and improved stability. In this review paper, we have discussed recent progress in implementing the ALD technique for depositing thin layers on various SSE configurations including lithium phosphorus oxynitride (LiPON), garnets, oxides, perovskites, sulphides,  $\text{Li}_3\text{BO}_3\text{--Li}_2\text{CO}_3$  (LBCO), and sodium super ionic conductors (NASICON). We have also highlighted the major areas for future research and development in the field. We believe that this review will be very helpful for directing future research on implementing ALD for synthesizing stable and high-performance SSEs with an engineered solid-electrolyte interface for next-generation electrochemical devices (e.g., Li-ion batteries, supercapacitors, and flow batteries).

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## 1. Introduction

Electrochemical energy storage and conversion devices are essential for successful integration of intermittent renewable energy resources (e.g., wind and solar) within the electric grid and subsequently reducing the carbon footprint from carbon-intensive energy sources (e.g., fossil fuels).<sup>1–4</sup> Among the

various types of electrochemical devices, primary and secondary batteries have been the focus of significant research and development.<sup>5,6</sup> In particular, lithium ion batteries (LIBs) are very promising energy storage devices with a high power/energy density, excellent specific energy density, high cell voltage, long cycle life, and low self-discharge.<sup>7</sup> Despite these exceptional properties, the energy density as well as the safety of existing LIBs must be further improved to fulfill the requirements demanded by next-generation electric vehicles (e.g., battery electric vehicles (BEVs), plug-in hybrid electric vehicles (PHEVs), and hybrid electric vehicles (HEVs)).

A typical lithium ion battery consists of a cathode (e.g., layered Li transition metal oxides), a graphitic anode, organic electrolytes (a mixture of organic solvent and lithium salts), and a polymeric microporous separator (e.g., Celgard®). The organic electrolytes containing Li salts usually possess relatively high conductivity ( $\sim 10^{-2}$  to  $10^{-3}$  S cm<sup>-1</sup>), good compatibility, and superior wettability. However, the utilization of organic electrolytes with low potential anodes (e.g., Li anodes) and high

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Table 1 Solid-state inorganic electrolytes formed by ALD<sup>a</sup>

Type of SSE	Chemical formula	ALD temp. (°C)	ALD synthesis/operation/substrate	GPC (Å per cycle)	Ionic conductivity (S cm <sup>-1</sup> )	Ref.
LiPON	Li <sub>0.99</sub> PO <sub>2.55</sub> N <sub>0.30</sub>	250	• Precursor: LiO <sup>t</sup> Bu, H <sub>2</sub> O, TMP • Plasma N <sub>2</sub> (PN) • Pressure: 200 mTorr	1.05	3 × 10 <sup>-7</sup> at room temperature	20
	Li <sub>0.95</sub> PO <sub>3.00</sub> N <sub>0.60</sub>	270–310	• Precursor: LiHMD, DEPA • Pressure: ~5 mbar	0.7	6.6 × 10 <sup>-7</sup> at 25 °C	21
	LiPON	300	• Precursor: LiHMD, DEPA • Pressure: ~5 mbar	0.7	ND	22
	Li <sub>2</sub> PO <sub>2</sub> N	200	• Precursor: LiO <sup>t</sup> Bu, DEPA	0.15	6.51 ± 0.36 × 10 <sup>-7</sup> at 35 °C	24
	Li <sub>2</sub> PO <sub>2</sub> N	300	• Pressure: 200 mTorr	0.9		
Garnet		250	• Precursor: LiO <sup>t</sup> Bu, DEPA • Pressure: 200 mTorr	0.6	ND	25
	Al-doped Li <sub>7</sub> La <sub>3</sub> Zr <sub>2</sub> O <sub>12</sub>	225	• Precursor: LiO <sup>t</sup> Bu, tris( <i>N,N'</i> -diisopropylformamidinato)lanthanum (LaFAMD), tetrakis(dimethylamido) zirconium (TDMAZ), trimethylaluminum (TMA) • Pressure: ~7 mTorr	ND	7.8 × 10 <sup>-5</sup> (200 °C) 1.2 × 10 <sup>-6</sup> (100 °C) 1 × 10 <sup>-8</sup> (25 °C)	26
					2 × 10 <sup>-8</sup> at 26 °C	
Oxide	Li <sub>5.1</sub> TaO <sub>z</sub>	225	• Precursor: LiO <sup>t</sup> Bu, H <sub>2</sub> O, Ta(OC <sub>2</sub> H <sub>5</sub> ) <sub>5</sub> • Subcycle: Li <sub>2</sub> O, Ta <sub>2</sub> O <sub>5</sub> • Pressure: ND	2.1		29
	LiAlO <sub>x</sub>	225	• Precursor: TMA, LiO <sup>t</sup> Bu, H <sub>2</sub> O • Subcycle: Al <sub>2</sub> O <sub>3</sub> , LiOH • Pressure: ~1 torr	1.54	ND	31
	LiNbO <sub>x</sub>	235	• Precursor: LiO <sup>t</sup> Bu, [Nb(OEt) <sub>5</sub> ], H <sub>2</sub> O • Subcycle: Li, Nb • Pressure: ND	ND	6 × 10 <sup>-8</sup> at 30 °C	32
	Li <sub>x</sub> SiO	225–300	• Precursor: LiO <sup>t</sup> Bu, tetraethylorthosilane (TEOS), H <sub>2</sub> O • Compound: Li <sub>2</sub> O, SiO <sub>2</sub> (subcycle: Li <sub>2</sub> O–SiO <sub>2</sub> ) • Pressure: ND	0.80–1.36	1.45 × 10 <sup>-6</sup> at 30 °C	33
	Li <sub>x</sub> Al <sub>y</sub> Si <sub>z</sub> O	290	• Compound: LiOH, Al <sub>2</sub> O <sub>3</sub> , SiO <sub>2</sub> (subcycle: LiOH–Al <sub>2</sub> O <sub>3</sub> –SiO <sub>2</sub> ) • Precursor: LiO <sup>t</sup> Bu, TMA, TEOS, H <sub>2</sub> O • Pressure: 60 mTorr	ND	10 <sup>-7</sup> to 10 <sup>-9</sup> at room temperature	34
Perovskite	Li <sub>0.32</sub> La <sub>0.30</sub> TiO <sub>z</sub>	225	• Precursor: La(thd) <sub>3</sub> , TiCl <sub>4</sub> , LiO <sup>t</sup> Bu, H <sub>2</sub> O, O <sub>3</sub> • Subcycle: TiO <sub>2</sub> –La <sub>2</sub> O <sub>3</sub> –Li <sub>2</sub> O • Pressure: 3 mbar	0.48	ND	36
Sulphide	Li <sub>x</sub> Al <sub>x</sub> S	150	• Precursor: LiO <sup>t</sup> Bu, tris(dimethylamido) aluminum (III) (TMDA–Al), H <sub>2</sub> S • Subcycle: (LiO <sup>t</sup> Bu)–H <sub>2</sub> S, TMDA–Al–H <sub>2</sub> S • Pressure: 1.2 torr	0.50	2.5 × 10 <sup>-7</sup>	40
LBCO	Li <sub>3</sub> BO <sub>3</sub> –Li <sub>2</sub> CO <sub>3</sub>	200, 260	• Precursor: LiO <sup>t</sup> Bu, TIB and O <sub>3</sub> • Subcycle: LiO <sup>t</sup> Bu–O <sub>3</sub> and TIB–O <sub>3</sub> • Pressure: ND	0.65	2.23 × 10 <sup>-6</sup> at 25 °C	48 and 49
NASICON	Li <sub>1.4</sub> Al <sub>0.4</sub> Ti <sub>1.6</sub> (PO <sub>4</sub> ) <sub>3</sub>	250	• Precursor: TMA, H <sub>2</sub> O	ND	1.5 × 10 <sup>-4</sup> at 25 °C	51

<sup>a</sup> ND: not detected.

voltage cathodes such as LiNi<sub>0.8</sub>Co<sub>0.1</sub>Mn<sub>0.1</sub>O<sub>2</sub> and LiNi<sub>0.80</sub>Co<sub>0.15</sub>Al<sub>0.05</sub>O<sub>2</sub> usually results in reduced stability along with accelerated degradation during extended and high-rate cycling. High toxicity, flammability, and the possibility of leakage are other disadvantages of liquid organic electrolytes. Therefore, there is a significant need for developing high-performance and inorganic solid state electrolytes (SSEs). Typically, SSEs are nonvolatile and compared to organic electrolytes, they exhibit

superior thermal and chemical stability with improved safety. SSEs also have higher energy density and if employed with a metallic Li-anode can potentially prevent the formation of lithium dendrites.<sup>8–10</sup>

The implementation of SSEs as the electrolyte or the separator has already been demonstrated for various electrochemical energy devices including supercapacitors, solid oxide fuel cells, and secondary batteries.<sup>9,10</sup> These devices commonly



include porous electrodes in their structure. Employing SSEs within these devices can be very inefficient since the solid electrolyte would not be able to diffuse through the porous microstructure. Indeed, using planar SSEs with porous electrodes commonly results in ultra-high interfacial resistance at the electrode/electrolyte interface. To overcome the challenges associated with the application of planar solid-state electrolytes, advanced manufacturing techniques are needed for fabricating nanoscale 3D-nanostructured SSEs capable of efficiently integrating with porous electrodes.<sup>9–11</sup> Atomic layer deposition (ALD),<sup>11</sup> chemical vapor deposition (CVD),<sup>12</sup> electron beam evaporation,<sup>13</sup> magnetron sputtering,<sup>14</sup> and spray drying<sup>15</sup> are some of the methods used for synthesizing and fabricating SSEs with a desired morphology and thickness.

Among these techniques, ALD has emerged as a versatile and robust synthesis method capable of forming high quality materials with a finely controlled thickness and nanostructure. ALD, similar to the “atomic layer epitaxy (ALE)” method, operates by alternating pulses of the precursor and co-reactant applied on the substrate surface. The ALD technique proceeds

through a series of distinct, repetitive, irreversible, and self-terminating chemical reactions between the precursor and co-reactant on the substrate. Moreover, the crystallinity can be readily controlled through the selection of a suitable precursor-co-reactant pair, substrate, and operating conditions (*e.g.*, pressure and temperature). Compared to other synthesis techniques (*e.g.*, CVD, magnetic sputtering, *etc.*), ALD has some unique attributes including (i) precise tunability of the film thickness, crystallinity and composition, (ii) excellent conformality and uniformity on 3D surfaces, (iii) remarkable chemical selectivity, and (iv) superior scalability.<sup>16–18</sup> Finally, ALD allows very thin single atomic level layer electrolyte deposition, overcoming the energy density limitation of the thickness (ceramic, *i.e.* >100  $\mu\text{m}$ ) of current SSEs.

Given these notable properties, it is very encouraging to implement ALD for synthesizing and fabricating different configurations of SSEs with desired properties. In this review paper, we have highlighted recent progress reported in the published literature for preparing SSEs using the ALD technique. In Section 2, the detailed principles of ALD for

**Table 2** Various SSEs on electrodes modified by ALD<sup>a</sup>

Electrode material	SSE	ALD temp. (°C)	ALD synthesis/operation/substrate	GPC (Å per cycle)	LIB performance (mA h g <sup>-1</sup> )	Ref.
LITP anode	LiPON	300	<ul style="list-style-type: none"> <li>• Precursor: LiHMD, DEPA</li> <li>• Pressure: ~5 mbar</li> </ul>	0.7	350	22
MWCNT@RuO <sub>2</sub>	LiPON	225	<ul style="list-style-type: none"> <li>• Precursor: LiO<sup>t</sup>Bu, DI H<sub>2</sub>O, TMP, N<sub>2</sub> gas</li> <li>• Pressure: 200 mTorr</li> </ul>	1.1	ND	23
NMC cathode	LiTaO <sub>3</sub>	225	<ul style="list-style-type: none"> <li>• Precursor: LiO<sup>t</sup>Bu, tantalum ethoxide (Ta(OEt)<sub>5</sub>), H<sub>2</sub>O</li> <li>• Subcycle: 1Li<sub>2</sub>O–6Ta<sub>2</sub>O<sub>5</sub></li> <li>• Pressure: ND</li> </ul>	ND	122–145	30
Li metal anode	Li <sub>x</sub> Al <sub>x</sub> S	150	<ul style="list-style-type: none"> <li>• Precursor: LiO<sup>t</sup>Bu, tris(dimethylamido) aluminum (iii) (TMDA-Al), H<sub>2</sub>S</li> <li>• Subcycle: Li<sub>2</sub>S–Al<sub>2</sub>S<sub>3</sub></li> <li>• Pressure: 1.2 torr</li> </ul>	0.50	ND	40

<sup>a</sup> ND: not detected.

**Table 3** Modification of the ALD layer at the interface between SSEs and electrodes<sup>a</sup>

SSE/electrode	ALD layer	ALD temp. (°C)	ALD synthesis/operation/substrate	GPC (Å per cycle)	Interfacial impedance	Ref.
Garnet/Li-metal	Al <sub>2</sub> O <sub>3</sub>	250	<ul style="list-style-type: none"> <li>• Precursor: TMA, H<sub>2</sub>O</li> <li>• Pressure: ND</li> </ul>	0.7	34 $\Omega\text{ cm}^2$	27
Garnet/Li-metal	ZnO	150	<ul style="list-style-type: none"> <li>• Precursor: diethyl zinc, H<sub>2</sub>O</li> <li>• Pressure: ND</li> </ul>	ND	20 $\Omega\text{ cm}^2$	28
Perovskite/anode	Li <sub>2</sub> O–Al <sub>2</sub> O <sub>3</sub>	225	<ul style="list-style-type: none"> <li>• Precursor: LiO<sup>t</sup>Bu, TMA, H<sub>2</sub>O</li> <li>• Pressure: 3 mbar</li> </ul>	2.8	ND	37
Sulphide/cathode	LiNbO <sub>x</sub>	235	<ul style="list-style-type: none"> <li>• Precursor: [LiO<sup>t</sup>Bu], [Nb(OEt)<sub>5</sub>]</li> <li>• Pressure: ND</li> </ul>	2	ND	42
LATP/Li metal anode	Al <sub>2</sub> O <sub>3</sub>	85	<ul style="list-style-type: none"> <li>• Precursor: TMA, water</li> <li>• Pressure: ND</li> </ul>	ND	150 k $\Omega$	51
LATP/sulphur cathode	Al <sub>2</sub> O <sub>3</sub>	120	<ul style="list-style-type: none"> <li>• Precursor: TMA, water</li> <li>• Pressure: ND</li> </ul>	1	ND	52

<sup>a</sup> ND: not detected.



synthesizing SSEs are listed, and the pioneering prior research conducted in the field is tabulated. Subsequently, we have cataloged various types of SSEs (*e.g.*, lithium phosphorus oxynitride (LiPON, Section 2.1), garnets (Section 2.2), oxides (Section 2.3), perovskites (Section 2.4), sulphides (Section 2.5),  $\text{Li}_3\text{BO}_3\text{--Li}_2\text{CO}_3$  (LBCO, Section 2.6), and sodium super ionic conductors (NASICON, Section 2.7)) successfully synthesized using ALD. We have also highlighted some of the major areas for future research and development (Section 3). In this review, we mainly focused on the three different approaches that ALD has been implemented to enhance ionic conductivity as well as LIB performance. Firstly, the ALD strategy was used to synthesize SSEs directly. Secondly, SSEs were deposited on the electrode *via* ALD. The strong dependence of enhanced ionic conductivity and LIB performance on the used precursor, ALD temperature, and thickness of SSEs is comprehensively summarised. Furthermore, various types of interfacial ALD layers were included between SSEs and electrodes, which improved the interfacial resistance. In addition, this review paper aims to direct future research on implementing ALD for preparing a new class of SSEs with a finely engineered structure to be used in various electrochemical energy devices (*e.g.*, next-generation Li-ion batteries, supercapacitors, and flow batteries).

## 2. ALD of SSEs

To synthesize various types of SSEs using the ALD technique, it is important to consider the attributes as well as the electrochemical performance expected from each class of SSEs. Based on initial analysis, the ALD method must be engineered for achieving any desired characteristic while maintaining a robust and stable performance. For conducting the ALD procedure, an appropriate precursor(s) and substrate must be selected and operating conditions (*e.g.*, temperature, pressure, and number of cycles) must be finely tuned. The choice of these critical properties directly influences the uniformity and conformality of the nanocoating and determines the rate of growth ( $\text{\AA}$  per cycle) of the thin film. In Table 1, we have provided a summary of ALD synthesis conditions for a series of SSEs. For synthesizing different types of SSEs, the ALD temperature, pressure, and precursors reported in the prior published literature are listed in Table 1. The growth per cycle (GPC) as well as the ionic conductivity ( $\text{S cm}^{-1}$ ) for as-prepared SSEs have also been tabulated in Table 1.

Typical SSEs (as shown in Table 1) are employed as the electrolyte materials for LIBs. Considering the focus of this review paper, we have summarized the ALD conditions adopted for synthesizing porous SSE/electrode structures (see Table 2). Along with ALD synthesis conditions, the discharge capacity ( $\text{mA h g}^{-1}$ ) achieved for the LIBs utilizing solid-state electrolytes has also been summarized in Table 2. Finally, given the importance of minimizing interfacial resistance for the electrochemical devices using solid state electrolytes, in Table 3, we have summarized the SSE/electrode structures reported in prior literature for a series of SSEs synthesized through ALD. The properties of the ALD layer, ALD operating details, and the magnitude of interfacial resistance for the as-prepared SSE/

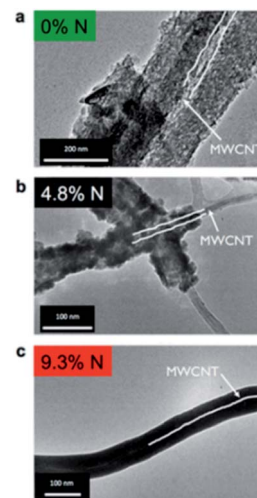


Fig. 1 TEM images of ALD LiPON deposited on a MWCNT sponge with (a) 0% N, (b) 4.8% N, and (c) 9.3% N content. Both (a) and (b) are polycrystalline, while (c) is amorphous. The diameter of the MWCNTs was 30–40 nm.<sup>20</sup>

electrode configurations have also been listed in Table 3. In the following, we have provided a comprehensive summary of each class of SSEs prepared with the atomic layer deposition technique.

### 2.1. LiPON-type SSEs

LiPON is an amorphous glassy material used as the electrolyte in thin film flexible batteries. LiPON electrolytes with the general formulation (Fig. 1) of  $\text{Li}_x\text{PO}_y\text{N}_z$  ( $x = 2y + 3z - 5$ ) were pioneered at the Oak Ridge National Laboratory.<sup>19</sup> It has been shown that the incorporation of nitrogen (N) within an oxide electrolyte ( $\text{Li}_2\text{O--P}_2\text{O}_5$ ) results in the formation of a new glassy electrolyte, *i.e.*, LiPON electrolyte.<sup>19</sup> In 2015, Rubloff and co-workers synthesized a LiPON electrolyte with the ALD technique through modulating the nitrogen content from 0 to 16.3%.<sup>20</sup> They demonstrated that the crystallinity of the LiPON

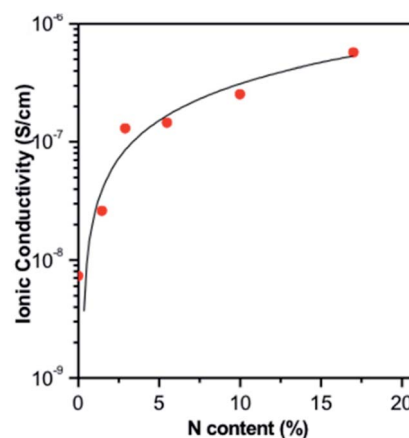


Fig. 2 Ionic conductivity of ALD LiPON films plotted as a function of N content along with curve fit to the data.<sup>20</sup>





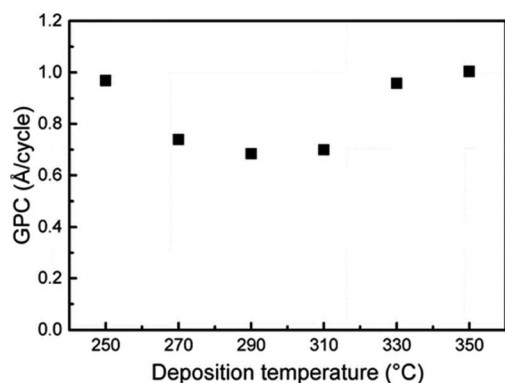


Fig. 3 GPC for the ALD process of LiHMDS-DEPA as a function of deposition temperature. The number of ALD cycles was fixed at 1200. The pulse and purge lengths for both precursors were 2 s.<sup>21</sup>

electrolyte ( $\text{Li}_{0.99}\text{PO}_{2.55}\text{N}_{0.30}$ ) depends strongly on the nitrogen content and found that 4.5% N is the transition point.<sup>20</sup>

As illustrated in Fig. 1, ALD LiPON samples with less than 4.5% N were polycrystalline upon depositing on a multi-walled carbon nanotube (MWCNT) sponge.<sup>20</sup> However, the crystalline morphology changed to an amorphous morphology when increasing the nitrogen content beyond 4.5% (see Fig. 1). They also showed that the ionic conductivity of the as-prepared ALD LiPON films increased with increasing nitrogen content (Fig. 2).<sup>20</sup> However, the highest ionic conductivity ( $6.6 \times 10^{-7} \text{ S cm}^{-1}$ ) among the as-prepared samples was achieved at room temperature due to the high level of the N to P ratio doped within the thin film.

The Karppinen group in 2015 reported a novel way of synthesizing a  $\text{Li}_{0.99}\text{PO}_{2.55}\text{N}_{0.30}$  film using ALD at 330 °C with lithium hexamethyldisilazide  $\text{LiN}(\text{SiMe}_3)_2$  (LiHMDS)-diethyl phosphorous-amidate  $\text{H}_2\text{NP}(\text{O})(\text{OC}_2\text{H}_5)_2$  (DEPA) (precursor-reactant).<sup>21</sup> They demonstrated a homogeneous film grown in a controlled manner by the number of ALD cycles having a relatively high GPC ( $\sim 0.7 \text{ Å per cycle}$ ) within the temperature range of 270–310 °C, as depicted in Fig. 3. The deposited LiPON film at 330 °C exhibited a high ionic conductivity ( $6.6 \times 10^{-7} \text{ S cm}^{-1}$ ) measured at 25 °C.<sup>21</sup> Later, they adopted the same precursor-reactant pair (LiHMDS-DEPA) to deposit a LiPON electrolyte by ALD and prepared Li-terephthalate (LiTP) hybrid electrodes for lithium ion batteries.<sup>22</sup> They achieved a conformal coating of  $\sim 40 \text{ nm}$  in thickness and demonstrated

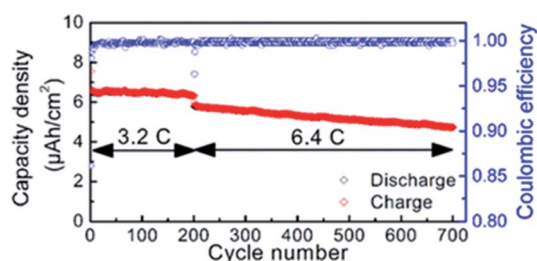


Fig. 4 Cycle life of LiPON-coated LiTP measured at high rates of 3.2 and 6.4C.<sup>22</sup>

97% capacity retention (after 200 cycles at 3.2C) with the as-prepared hybrid electrodes (see Fig. 4).<sup>22</sup> After extended cycling experiments ( $>500$  cycles) at an ultra-high C-rate (6.4C), the capacity retention was 81% confirming superior cycling stability with the ALD-prepared LiPON electrolyte.<sup>22</sup>

To further explore the efficacy of LiPON electrolytes for LIBs, Lin *et al.* demonstrated the critical role of a solid-state LiPON electrolyte as a nanocladding layer protecting the 3D-structure of the electrode from side reactions, thus enhancing cyclability (see Table 2), as illustrated in Fig. 5(a and b). According to Fig. 5(a), depositing a LiPON layer (SSE) *via* ALD on a  $\text{MWCNT@RuO}_2$  (electrode) structure significantly enhanced the capacity retention ( $>95\%$ ) compared to the bare  $\text{MWCNT@RuO}_2$  electrodes. Compared to the bare  $\text{MWCNT@RuO}_2$  electrode that usually experiences severe volume expansion during cycling,<sup>23</sup> the implementation of LiPON nanocoating significantly improved the cyclability for two major reasons: (i) the LiPON layer enhanced the Li ion conductivity at the interface between the electrolyte and the electrode; (ii) it serves as an efficient protective layer constraining the electrode microstructure and subsequently preventing severe mechanical deformation during a lithiation/delithiation process over extended cycling.<sup>23</sup>

In another pioneering study, Gregorczyk *et al.* carried out thermal ALD using lithium *tert*-butoxide ( $\text{LiO}^t\text{Bu}$ ) and DEPA precursors and were able to successfully synthesize LiPON (N/P ratio: 1).<sup>24</sup> In contrast to previous reports, they demonstrated a possible polymorph phase and achieved a conformal thin film (stoichiometrically close to  $\text{Li}_2\text{PO}_2\text{N}$ ) with an ionic conductivity of  $\sim 6.51 \times 10^{-7} \text{ S cm}^{-1}$  at 35 °C.<sup>24</sup> The film was deposited with a linear GPC ranging from *ca.* 0.15 (200 °C) to 0.9 Å per cycle (300 °C) and exhibited an exceptional electrochemical stability within the potential window of 0–5.3 V *versus*  $\text{Li/Li}^+$ .<sup>24</sup> The same group assembled 3D thin-film solid-state batteries (3D TSSB) with a  $\text{LiV}_2\text{O}_5$  cathode and  $\text{SnN}_x$  anode and achieved a specific

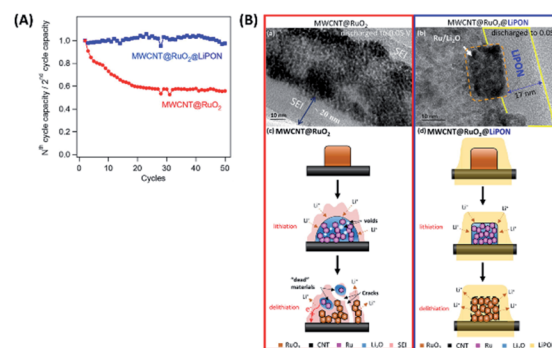


Fig. 5 (A) Normalized capacities (capacity retention) of  $\text{MWCNT@RuO}_2$  vs.  $\text{MWCNT@RuO}_2\text{@LiPON}$  (all gravimetric capacities are normalized to the mass of  $\text{RuO}_2$ ) and (B) high-magnification transmission electron microscopy images of (a) 3D  $\text{MWCNT@RuO}_2$  electrodes (no protection) and (b) LiPON-protected  $\text{MWCNT@RuO}_2$  electrodes, discharged to 0.05 V vs.  $\text{Li/Li}^+$ . (c and d) Schematic diagram of the mechanisms comparing the (c) bare  $\text{MWCNT@RuO}_2$  electrode and (d) LiPON-protected  $\text{MWCNT@RuO}_2$  to demonstrate the effect of the LiPON cladding layer, which enhances the mechanical stability and electron transport pathways.<sup>23</sup>



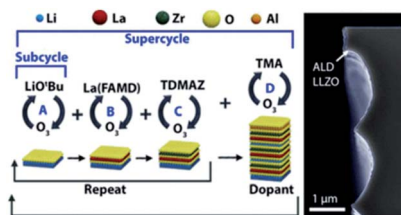


Fig. 6 Schematic representation of an ALD supercycle for the growth of Al-doped LLZO films and the corresponding TEM micrograph.<sup>26</sup>

capacity of  $37 \mu\text{A h cm}^{-2} \mu\text{m}$  (normalized to the cathode thickness) with only 0.02% per-cycle capacity loss. It is important to note that the 3D structured TSSB enhanced the rate performance along with the round-trip efficiency and increased the areal capacity, simultaneously.<sup>25</sup> From the above comparison, the most important conclusion is to maximize Li ion mobility in the LiPON electrolyte, which depends on accommodation N in bridging sites while keeping a high amount of charge carrier. It means that the concentration of Li according to  $\text{LiPO}_4$  and outlying O ions should be minimized. Based on these critical observations, the influence of the ALD parameters on the chemical composition, film thickness, internal structure as well as the electrolyte conductivity can be established.

Adopting ALD technique, SSEs with extremely thin film thickness ( $\sim$  few hundred nanometers) can be prepared for ultra-compact LIBs. Also, it should be noted that ALD of LiPON electrolytes is relatively difficult since they need Li containing cathodes (*i.e.*, two-element operation) that is cumbersome to accomplish for a typical 3D SSE battery architecture. To ease the operation of ALD-LiPON electrolytes, further research must be dedicated for developing multi-element ALD setups using series of different precursors. These type of ALD systems can also significantly reduce the ALD cycle time due to employing various precursors simultaneously.

## 2.2. Garnet-type SSEs

Garnet-type materials are very promising solid state electrolytes for LIBs thanks to their remarkable properties including superior energy density, electrochemical stability, high-temperature stability, and safety. The general formula of garnet-type electrolytes is  $\text{A}_3\text{B}_2(\text{XO}_4)_3$ , where A and B represents crystallographic cationic co-ordination environment with X cation.

To date, several high-performance garnet-type electrolytes have been synthesized, including  $\text{Li}_5\text{La}_3\text{Ta}_2\text{O}_{12}$ ,  $\text{Li}_5\text{La}_3\text{Nb}_2\text{O}_{12}$ ,  $\text{Li}_7\text{La}_3\text{Sn}_2\text{O}_{12}$ ,  $\text{Li}_5\text{Nd}_3\text{Sb}_2\text{O}_{12}$ , and  $\text{Li}_3\text{Ln}_3\text{Te}_2\text{O}_{12}$ , with the ionic conductivities measured within the range of  $10^{-6}$  to  $10^{-4} \text{ S cm}^{-1}$  at ambient temperature.<sup>9</sup> Dasgupta *et al.* employed the thermal ALD technique to synthesize garnet-type Al-doped  $\text{Li}_7\text{La}_3\text{Zr}_2\text{O}_{12}$  (LLZO) SSEs.<sup>26</sup> The ALD deposited Al-doped LLZO films demonstrated high purity, tunable composition, and self-limiting behavior, as shown in Fig. 6. They also conducted a post-annealing treatment on different substrates to form a cubic-phase (c-LLZO) at  $555^\circ\text{C}$  from its primary tetragonal-phase (t-LLZO) at room temperature.<sup>26</sup> Through their

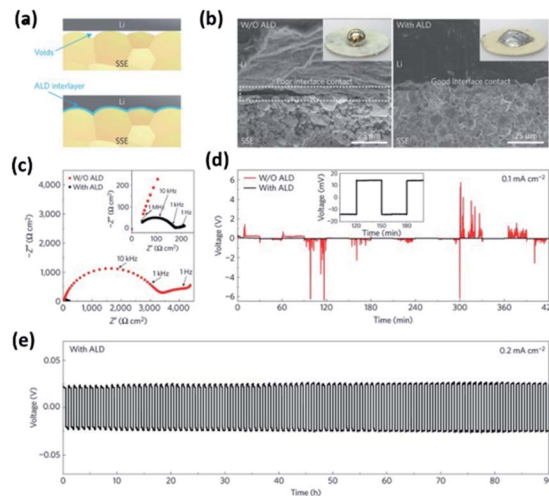


Fig. 7 Characterization of a garnet-type SSE/Li metal interface. (a) Schematic of the wetting behavior of the garnet surface with molten Li. (b) Scanning electron microscopy (SEM) images of the garnet-type SSE/Li metal interface. Without ALD- $\text{Al}_2\text{O}_3$  coating, the SSE has a poor interfacial contact with Li metal even on heating. With the help of ALD- $\text{Al}_2\text{O}_3$  coating on garnet, Li metal can uniformly bond with the SSE at the interface on heating. The inset shows the photos of melted Li metal on top of the garnet surface clearly demonstrating classical wetting behavior for the ALD-treated garnet-type SSE surface. (c) Comparison of Nyquist plots of the symmetric Li non-blocking garnet cells. The inset shows the enlarged impedance curve of the ALD-treated cell. (d) Comparison of dc cycling for symmetric cells at  $0.1 \text{ mA cm}^{-2}$ . The inset shows the magnified curve of the ALD-treated cell. (e) Cell voltage profile during extended cycling.<sup>27</sup>

comprehensive analysis, they concluded that thermal ALD is a very efficient technique for depositing ultrathin films with superior ionic conductivity and electrochemical stability enabling conformal coating of SSE/electrode interfaces for solid-state batteries.<sup>26</sup>

It was also demonstrated that the wettability along with the interfacial resistance of garnet-like

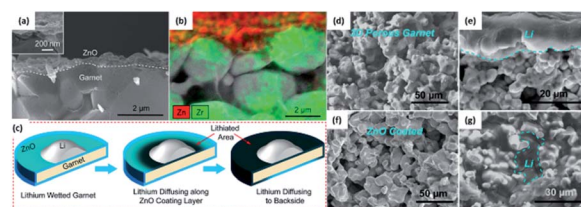


Fig. 8 Characterization of ALD ZnO coating to improve the surface wettability of garnet-type SSEs with molten lithium. Cross-sectional (a) SEM images and (b) elemental mapping of the garnet electrolyte coated with a 50 nm ALD ZnO layer. The inset of (a) shows a cross-sectional SEM image of the SSE/ZnO interface at higher magnification. (c) Schematic of the lithium diffusion process along the ZnO coating layer on the SSE surface. The cross-sectional SEM images of (d) the pristine and (e) the lithium infiltrated porous SSE with a porosity of 60–70%. (f) The cross-sectional SEM image of the porous garnet coated with a conformal ZnO surface layer using the ALD process. (g) The cross-sectional SEM images of a lithium infiltrated porous SSE with ZnO surface treatment, where almost all pores have been filled with Li metal. The Li metal area has been marked with a cyan dashed line.<sup>28</sup>



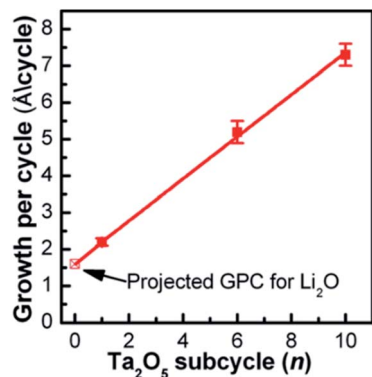


Fig. 9 The GPC of the lithium tantalate thin films as a function of  $\text{Ta}_2\text{O}_5$  subcycle number, using pulsing sequences of  $1 \times \text{Li}_2\text{O} + n \times \text{Ta}_2\text{O}_5$  ( $n = 1, 6$ , and  $10$ ).<sup>29</sup>

$\text{Li}_7\text{La}_{2.75}\text{Ca}_{0.25}\text{Zr}_{1.75}\text{Nb}_{0.25}\text{O}_{12}$  (LLCZN) SSEs can be significantly enhanced *via* coating an  $\text{Al}_2\text{O}_3$  layer (see Table 3).<sup>27</sup> The wettability and stability of LLCZN were dramatically improved (Fig. 7(a and b)) leading to a significant decrease in interfacial resistance from  $1710$  to  $34 \Omega \text{ cm}^2$  (see Fig. 7(c)). The decreased interfacial resistance was ascribed to three major reasons: (i) conformal ALD coating enabled a more efficient contact between the Li metal and the garnet-like SSE, (ii) the ALD coated  $\text{Al}_2\text{O}_3$  layer provided a highly conductive pathway for Li ions transferring between the garnet and Li metal anode, and (iii) the implementation of the protective  $\text{Al}_2\text{O}_3$  layer inhibited the impurity growth and improved the mechanical stability during lithium intercalation/deintercalation.<sup>27</sup> The authors also conducted long-duration cycling experiments and confirmed the effect of the ALD-coated  $\text{Al}_2\text{O}_3$  layer on enhancing cycling stability (see Fig. 7(d)).<sup>27</sup>

In a following study, a similar approach was adopted and the wettability of a garnet-type SSE surface was significantly improved and an intimate contact between the Li metal and SSEs was achieved using an interfacial layer of ALD ZnO coating

(see Fig. 8). It was shown that the ALD-coated ZnO layer substantially decreases the interfacial resistance (the interfacial impedance reached as low as  $20 \Omega \text{ cm}^2$ ).<sup>28</sup> Therefore, adopting ALD for nanocoating protective yet conductive layers on garnet-type electrolytes can hugely improve the wettability as well as the mechanical stability during lithium intercalation/deintercalation processes.

### 2.3. Oxide-type SSEs

One of the pioneering studies on implementing ALD to prepare lithium tantalate thin films at low temperature ( $225^\circ \text{C}$ ) was reported by the Sun group in 2003.<sup>29</sup> They demonstrated a lithium tantalate thin film as a stable and conductive coating layer with relatively high conductivity ( $10^{-8}$  to  $10^{-5} \text{ S cm}^{-1}$ ) at room temperature.<sup>29</sup> Lithium *tert*-butoxide ( $\text{LiO}^t\text{Bu}$ )– $\text{H}_2\text{O}$ –tantalum(v) ethoxide ( $\text{Ta}(\text{OEt})_5$ )– $\text{H}_2\text{O}$  was used as a precursor in a series of sequential pulses.<sup>29</sup> The Sun group concluded that the GPC of the deposited film strongly depended on the number of  $\text{Ta}_2\text{O}_5$  subcycles (*i.e.*, 2.2, 5.2, and  $7.3 \text{ \AA}$  per cycle) conducted during a complete ALD cycle ( $1 \times \text{Li}_2\text{O} + n \times \text{Ta}_2\text{O}_5$ , where  $n$  is equal to 1, 6, and 10, respectively) as illustrated in Fig. 9.<sup>29</sup> The deposited oxide layer demonstrated a well-controlled film thickness, conformal composition, excellent step coverage, and acceptable ionic conductivity ( $2 \times 10^{-8} \text{ S cm}^{-1}$ ) at room temperature.<sup>29</sup>

In a subsequent study, the same group use the ALD method to modify a lithium tantalate thin film (electrolyte) on  $\text{LiNi}_{1/3}\text{Mn}_{1/3}\text{Co}_{1/3}\text{O}_2$  (NMC) electrodes. The ALD-coated NMC cathodes showed outstanding electrochemical performance even under high voltage operating conditions.<sup>30</sup> It is important to note that the electrochemical performance of the ALD-coated NMC cathodes was greatly influenced by the thickness of the nanocoated layer as well as the operating conditions. They considered five different cathode configurations labeled NMC-0, NMC-2, NMC-5, NMC-10, and NMC-20 based on the number of ALD cycles (*i.e.*, 0, 2, 5, 10, and 20, respectively) and concluded that the NMC-5 cathode outperformed the other cathode configurations under various cycling conditions,

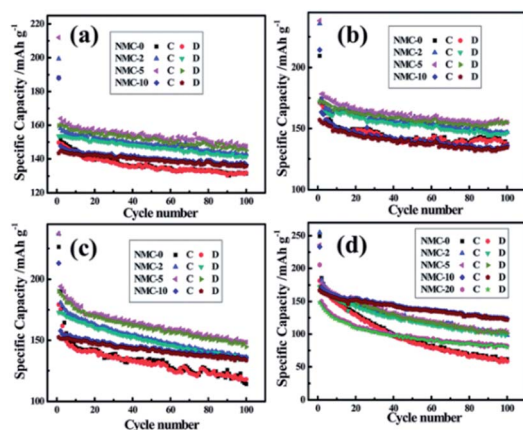


Fig. 10 The comparison of the cycle performance of NMC-0, NMC-2, NMC-5, NMC-10, and NMC-20 electrodes at a current density of  $160 \text{ mA g}^{-1}$  at room temperature in the voltage range of (a)  $3.0$ – $4.5 \text{ V}$ , (b)  $3.0$ – $4.6 \text{ V}$ , (c)  $3.0$ – $4.7 \text{ V}$ , and (d)  $3.0$ – $4.8 \text{ V}$ .<sup>30</sup>

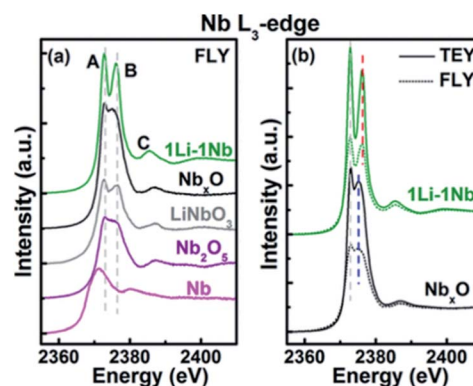


Fig. 11 Nb  $L_3$ -edge XANES spectra: (a) fluorescence yield (FLY) XANES spectra of ALD thin films and standard powders ( $\text{LiNbO}_3$ ,  $\text{Nb}_2\text{O}_5$ , and Nb) and (b) total electron yield and FLY XANES spectra of  $1\text{Li}-1\text{Nb}$  and  $\text{Nb}_x\text{O}$  thin films.<sup>32</sup>



whereas NCM-10 exhibited superior cyclability, high discharge capacity ( $122 \text{ mA h g}^{-1}$ ), and remarkable capacity retention for high voltage operation (3.0–4.8 V) as depicted in Fig. 10. These observations confirmed that an optimal coating thickness is required for maintaining the structural stability while minimizing the mass transport overpotential induced by the coated layer.<sup>30</sup>

Later, Comstock and Elam conducted ALD for coating an Al layer as a replacement for Ta to form lithium aluminum oxide ( $\text{LiAlO}_x$ ).<sup>31</sup> They used trimethylaluminum ( $\text{Al}_2\text{O}_3$ )– $\text{H}_2\text{O}$  and lithium *tert*-butoxide ( $\text{LiOH}$ )– $\text{H}_2\text{O}$  as the precursor and found that the film composition can be finely tuned through modulating  $\text{LiOH}$ – $\text{H}_2\text{O}$  cycles.<sup>31</sup> They also achieved a relatively high growth rate (*i.e.*,  $1.5 \text{ \AA}$  per cycle at  $\leq 50\%$   $\text{LiOH}$ – $\text{H}_2\text{O}$  cycles) during the deposition process.<sup>31</sup> Their observation revealed that a high percentage of Li cations within the ALD  $\text{LiAlO}_x$  thin film was formed when  $\text{LiOH}$  cycles were  $>50\%$ ; however, a stable growth rate was maintainable only within 20–30 cycles.<sup>31</sup> Furthermore, they were able to incorporate a high Li content within ALD-coated  $\text{LiNbO}_x$  films *via* increasing the Li-to-Nb subcycle ratio (1 : 1, 1 : 2, 1 : 4, and 2 : 1, having a GPC of 1.82, 2.05, 2.54, and  $2.87 \text{ \AA}$ , respectively).<sup>32</sup> They successfully conducted ALD of a  $\text{LiNbO}_x$  thin film at  $235^\circ\text{C}$  with a well-controlled composition, conformality, and thickness and achieved a relatively high ionic conductivity ( $6 \times 10^{-8} \text{ S cm}^{-1}$ ) at room temperature for the ALD-coated  $\text{LiNbO}_x$  sample prepared with a Li/Nb subcycle ratio of 1 : 4.<sup>32</sup> As shown in Fig. 11, the thin film was examined by X-ray absorption near edge structure (XANES) spectroscopy and an amorphous morphology was confirmed with coexisting Nb and  $\text{Nb}^{5+}$  in a distorted octahedral structure.<sup>32</sup>

In another pioneering study, the Sun group reported ALD of lithium silicate ( $\text{Li}_x\text{SiO}$ , LSO) at different temperatures.<sup>33</sup> They reported linear growth rates of 0.80, 1.00, 1.26, and  $1.36 \text{ \AA}$  per cycle at 225, 250, 275, and  $300^\circ\text{C}$ , respectively.<sup>33</sup> They combined ALD  $\text{Li}_2\text{O}$  and  $\text{SiO}_2$  subcycles and demonstrated ALD-coated thin films with a uniform composition and self-limiting growth in the temperature range of  $225$ – $300^\circ\text{C}$ . They observed that the  $\text{Li}_2\text{O}$  subcycle facilitates the growth of a  $\text{SiO}_2$  layer and concluded that the ratio of Li to Si within the as-prepared thin films is maintained close to the stoichiometry of  $\text{Li}_4\text{SiO}_4$  according to the X-ray photoelectron spectroscopy

(XPS) analysis (see Fig. 12).<sup>33</sup> The Sun group also reported that the lithium silicate at  $250^\circ\text{C}$  exhibits a relatively high  $\text{Li}^+$  ion conductivity ( $1.45 \times 10^{-6} \text{ S cm}^{-1}$  at  $30^\circ\text{C}$ ), and upon doping Al into lithium silicate ( $\text{Li}_x\text{Al}_y\text{Si}_z\text{O}$  (LASO)), the conductivity substantially decreases ( $\sim 10^{-9}$  to  $10^{-7} \text{ S cm}^{-1}$ ) with apparent activation energy in the range of 0.46–0.84 eV, depending on the chemical composition of the films.<sup>33</sup> The subsequent electrochemical measurement confirmed the presence of conformal and pinhole-free deposited thin films (thickness: 6–10 nm).<sup>34</sup>

#### 2.4. Perovskite-type SSEs

The perovskites-type SSEs of general formula  $\text{ABO}_3$  are high-performance solid-state materials with superior electrochemical stability.<sup>35</sup> As one of the most promising lithium ion-conducting SSEs, lithium lanthanum titanate perovskite ceramics or  $\text{Li}_{3x}\text{La}_{(2/3)-x}\text{TiO}_3$  (LLTO) have experienced a surge in attention due to their remarkably high bulk ionic conductivity ( $\sim 10^{-3} \text{ S cm}^{-1}$ , comparable to that of polymer/liquid electrolytes) and wide voltage stability window at room temperature.<sup>35</sup> The high conductivity of LLTO could be elaborated by considering the LLTO structure;  $\text{Li}^+$  and  $\text{La}^{3+}$  are uniformly distributed within A sites in the cubic phase and orderly arranged in a doubled perovskite structure that causes slight tilting of octahedra. Therefore, at low-temperature operation, the mobility of Li ions within the 2D structure (*i.e.* *a* and *b*) is relatively fast while the vibration of oxygen atoms in these type of morphologies slows down the transport in *c*-direction.<sup>35</sup>

In 2010, Aaltonen and co-worker reported on synthesizing  $\text{Li}_{0.32}\text{La}_{0.30}\text{TiO}_z$  (LLT) thin films using the ALD technique with  $\text{TiO}_2$ ,  $\text{La}_2\text{O}_3$ , and  $\text{Li}_2\text{O}$  (or  $\text{LiOH}$ ) subcycles at  $225^\circ\text{C}$ . The as-deposited thin films were converted from an amorphous to a crystalline structure (as confirmed by X-ray diffraction (XRD)) through implementing a post-annealing step in an oxygen environment at  $800^\circ\text{C}$  (see Fig. 13).<sup>36</sup> However, the as-grown films were unstable against low-voltage anode materials. To overcome this limitation, adopting the ALD technique, they have modified an interfacial layer of  $\text{Li}_2\text{O}$ – $\text{Al}_2\text{O}_3$ , between the LLT and anode material.<sup>37</sup> They were able to successfully coat a  $\text{Li}_2\text{O}$ – $\text{Al}_2\text{O}_3$  protective layer through combining multiple ALD substeps including lithium oxide/hydroxide and aluminum oxide processes. From the above recent research, it is realised that the ALD method is a very potential method for the

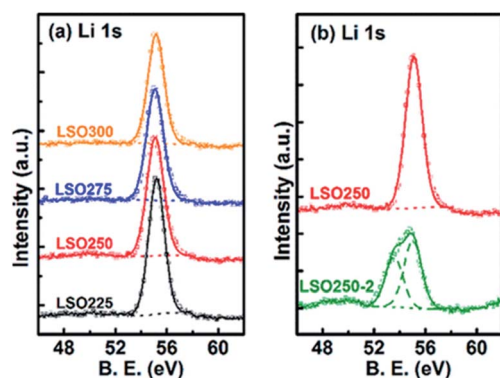


Fig. 12 Deconvolution of Li 1s XPS spectra of lithium silicate thin films deposited (a) at different temperatures and (b) with different Li sub-cycle numbers.<sup>33</sup>

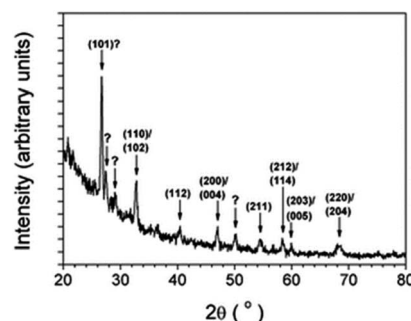


Fig. 13 Grazing incidence XRD pattern of an about 100 nm-thick LLT film annealed in oxygen at  $800^\circ\text{C}$  for 3 h.<sup>36</sup>





preparation of multi-element SSEs through ALD subcycles. In addition, an ALD-coated thin film can serve as a protective layer stabilizing the anode material.

## 2.5. Sulphide-type SSEs

Solid-state sulphide-based electrolytes have several unique properties including a high ionic conductivity ( $10^{-4}$  to  $10^{-2}$  S cm $^{-1}$ ), wide electrochemical stability window, and favorable mechanical properties (*e.g.*, formability). The high ionic conductivity was mainly attributed to the following two factors: (i) reduced grain boundary resistance and (ii) minimised void.<sup>38</sup> Despite these unique attributes, the sulphide-based SSEs commonly suffer from severe issues such as poor cycle life and low performance/cyclability primarily due to high interfacial resistance between the SSE and the electrode.<sup>38,39</sup> To reduce interfacial impedance, Elam *et al.* used the ALD technique for decorating ultrathin lithium aluminium sulphide ( $\text{Li}_x\text{Al}_x\text{S}$ ) thin films on Li metal anodes.<sup>40</sup>  $\text{Li}_x\text{Al}_x\text{S}$  ALD was carried out following the ALD procedure previously developed for coating  $\text{Li}_2\text{S}$  films using  $(\text{LiO}^t\text{Bu})\text{-H}_2\text{S}$  (reactant-precursor pair)<sup>41</sup> along with  $\text{Al}_2\text{S}_3$  ALD based on tris(dimethylamido)aluminum(III) (TMDA-Al) and  $\text{H}_2\text{S}$  on Li metal. Indeed, the atomic layer deposition of  $\text{Li}_x\text{Al}_x\text{S}$  is controlled by the ALD cycles of  $\text{Li}_2\text{S}$  and  $\text{Al}_2\text{S}_3$  as schematically shown in Fig. 14(a) where the deposited film is composed of  $\text{Li}_2\text{S}/\text{Al}_2\text{S}_3$  (1 : 1 ratio). They also achieved a relatively high ionic conductivity ( $2.5 \times 10^{-7}$  S cm $^{-1}$ ) for the as-deposited films, as depicted in Fig. 14(b). The high ionic conductivity of the ALD deposited  $\text{Li}_x\text{Al}_x\text{S}$  film, which not only stabilises at the electrolyte–Li electrode interface, but also highly suppresses Li dendrite growth. Additionally, they were able to reduce the interfacial impedance up to 5 fold approaching the contact resistance commonly observed for Li metal anodes with organic electrolytes (Fig. 14(c and d)).<sup>40</sup>

Although the contact impedance between the electrode and solid state sulphide-based electrolytes was significantly reduced through the ALD process, several major issues remained

unresolved for achieving acceptable performance. Sulphide-based SSEs like  $\text{Li}_{10}\text{GeP}_2\text{S}_{12}$  (LGPS) commonly demonstrate severe instability with the  $\text{LiNi}_{0.8}\text{Co}_{0.1}\text{Mn}_{0.1}\text{O}_2$  (NMC811) cathode during the charging process due to the formation of  $\text{Li}_2\text{S}$ . Some prior studies have focused on improving the stability at the electrode/electrolyte interface. Sun and co-worker deposited a well-controlled and ultrathin film  $\text{LiNbO}_x$  (LNO) on a NMC811 cathode *via* ALD and assembled with a LGPS electrolyte.<sup>42</sup> This LNO layer assembled as an interfacial layer between the electrolyte and cathode. They reported that the deposited thin film stabilizes the interface, demonstrates high bulk ionic conductivity ( $2.07 \times 10^{-3}$  S cm $^{-1}$ ), and improves the electrochemical performance, as shown in Fig. 15(a–e). Given these significant improvements, it is clear that as-deposited LNO film on the NMC811 structure improves the ionic conductivity and suppresses the side reaction resulting in an enhanced electrochemical performance. Using the ALD technique, LNO was deposited with different controlled thicknesses. However, a thickness of 5 nm enabled better electrochemical properties.<sup>42</sup> Hence, this ALD method is very helpful to synthesize ultrathin films with desired thickness for better LIB performance.

## 2.6. LBCO-type SSEs

Berzins *et al.* proposed a  $\text{Li}_3\text{BO}_3\text{-Li}_2\text{CO}_3$  (LBCO) SSE in 1977 (ref. 43) and since then, its various structures including glassy and crystalline phases have been studied by several other

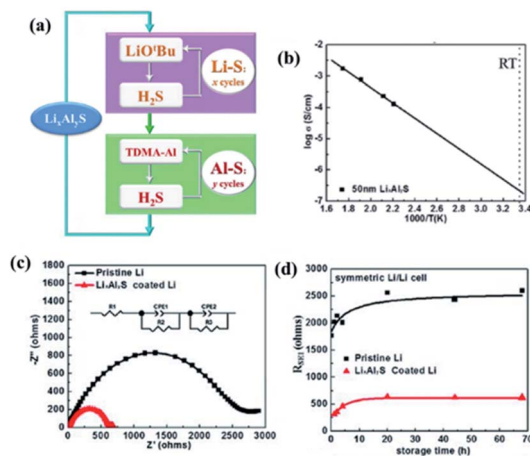


Fig. 14 (a) Schematic illustration of  $\text{Li}_x\text{Al}_x\text{S}$  ALD, (b) Arrhenius plot for temperature-dependent ionic conductivity measured using a 50 nm  $\text{Li}_x\text{Al}_x\text{S}$  film, (c) AC impedance spectra of Li/electrolyte/Li symmetric cells using both pristine Li and  $\text{Li}_x\text{Al}_x\text{S}$ -coated Li after 68 h storage, and (d)  $R_{\text{SEI}}$  of Li/electrolyte/Li symmetric cells *versus* storage time.<sup>40</sup>

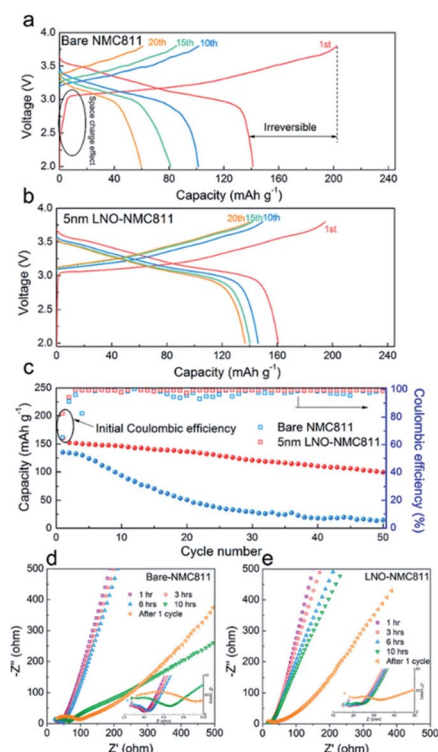


Fig. 15 Electrochemical characterization of bare and LNO-coated NMC811 in LIBs. (a and b) Charge/discharge profiles, (c) cycling performance, and (d and e) EIS plots of batteries at various resting times and after the charge/discharge test.<sup>42</sup>



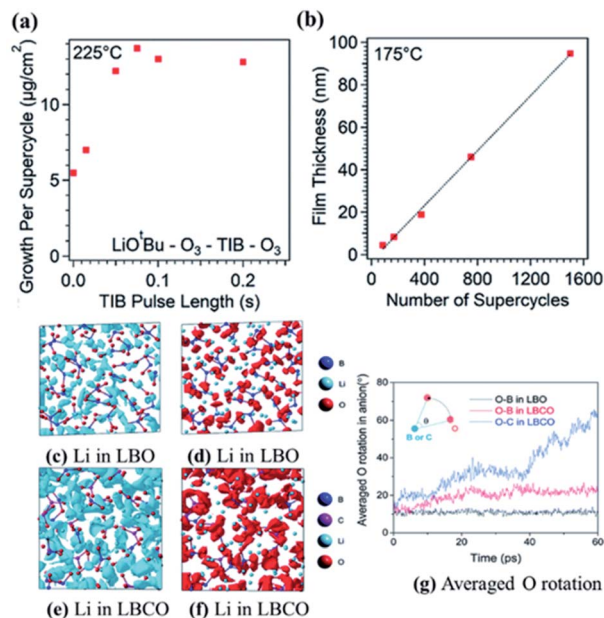


Fig. 16 Characterization of ALD film growth with an *in situ* quartz crystal microbalance, showing (a) saturation of the growth rate with increasing TIB pulse time, and spectroscopic ellipsometry showing (b) linearly increasing film thickness with the number of supercycles. (c–f) Iso-surfaces of the ionic probability densities evaluated from ionic trajectories calculated over 60 ps AIMD at 500 K. (g) Average oxygen rotational displacements in borate and carbonate anions during AIMD. The iso-surfaces are plotted using an isosurface value of  $2P_0$  ( $P_0$  represents the average probability density), for (c) Li in LBO, (d) O in LBO, (e) Li in LBCO, and (f) O in LBCO. (g) Averaged oxygen rotational displacements of LBO and LBCO during AIMD at 500 K.<sup>47</sup>

groups.<sup>44–46</sup> Recently, a relatively high conductivity ( $10^{-5}$  S cm<sup>-1</sup>) was reported for LBCO through adjusting Li and carbon contents within the  $\text{Li}_3\text{BO}_3$ – $\text{Li}_2\text{CO}_3$  microstructure.<sup>47</sup> Despite having favorable attributes, synthesizing LBCO-type SSEs using the ALD technique has not been investigated thoroughly in the field. In one of the pioneering studies on the ALD of LBCO thin films, Dasgupta and co-worker performed LBCO ALD employing a 1 : 1 ratio of  $\text{LiO}^t\text{Bu}$ – $\text{O}_3$  subcycles to triisopropyl borate (TIB)– $\text{O}_3$  subcycles (see Fig. 16(a)) and reported a linear GPC of 0.65 Å per cycle as measured by spectroscopic ellipsometry (see Fig. 16(b)).<sup>48</sup> The deposited film was shown to be the result of a self-limiting reaction, where a linear growth rate was maintained over a range of deposition temperatures. The structure and properties of the deposited film were tuned by temperature and pre-treatment conditions.<sup>48</sup> They also concluded that a consistent film growth can be preserved if the substrate temperature is kept within 200–260 °C.<sup>48</sup>

In a subsequent study, the same research group achieved a higher ionic conductivity ( $\sim 2.23 \times 10^{-6}$  S cm<sup>-1</sup> at 25 °C) *via* modulating the carbon to boron content in a mixture of  $\text{Li}_2\text{CO}_3$  and  $\text{Li}_3\text{BO}_3$  by following the ALD method.<sup>48,49</sup> It was shown that the ionic conductivity of the deposited thin film is a strong function of the carbon content ( $\text{Li}_2\text{CO}_3$  ratio) within the mixture.<sup>48,49</sup> An increased  $\text{Li}_2\text{CO}_3$  content resulted in increased  $\text{Li}^+$  mobility as demonstrated in Fig. 16(c–g). Moreover, the

stability of the LBCO film against the Li anode was confirmed through *in situ* analysis of a cell stack assembled with ALD  $\text{V}_2\text{O}_5$  (cathode)/ALD LBCO (SSE)/Li metal (anode) (see Fig. 17(a)).<sup>48,49</sup> The ALD LBCO exhibited excellent cycling stability with the Li metal anode and delivered high coulombic efficiency for over 150 cycles with negligible capacity fading, as illustrated in Fig. 17(b).<sup>48,49</sup> Therefore, the increased ionic conductivity and electrochemical performance indicate that the implementation of the ALD method is very advanced not only for the fabrication of ultrathin film SSEs, but also for forming interfacial or protective layers for the next generation of SSE batteries.

## 2.7. NASICON-types SSEs

Sodium super ionic conductors (NASICON) have found many applications as single-ion conductors in a variety of electrochemical devices. A very high ionic conductivity ( $\sim 0.1$  mS cm<sup>-1</sup>) and exceptional structural stability are the major attributes of NASICON-type solid-state electrolytes. Among all NASICON-like SSEs, the Ti based one [ $\text{LiTi}_2(\text{PO}_4)_3$ , or LTP] is a widely used  $\text{Li}^+$  ion conductor with a relatively high ionic conductivity compared to other tetravalent metal ions. However, to implement LTP as a solid-state electrolyte for high-performance LIBs, the ionic conductivity of this NASICON-type material must be improved. To this end, partially replacing Ti within the material structure through doping a larger size cation to form  $\text{Li}_{1.4}\text{Al}_{0.4}\text{Ti}_{1.6}(\text{PO}_4)_3$  (LATP) has been demonstrated to hugely improve the ionic conductivity ( $7 \times 10^{-4}$  S cm<sup>-1</sup>). The improved ionic conductivity upon Al doping was majorly due to enhanced Li mobility as a result of Li–Li repulsion. Hence, the formation of vacancies at M1 sites enhances Li mobility.<sup>8,50</sup> Despite having higher ionic conductivity, the structure of LATP becomes unstable when used in direct contact with a Li metal anode due to an unsteady phase formed at the interface of LATP/Li (in Li– $\text{O}_2$  systems).<sup>51</sup> For Li–S batteries, the implementation of LATP with a Li anode results in the formation of polysulphide reduced LATP, where the polysulphides deteriorate the performance of the LATP SSE.<sup>52</sup> To enhance the performance of LATP in these structures, Sun *et al.* adopted the chemical-wet synthesis technique for preparing LATP and subsequently employed ALD to coat  $\text{Al}_2\text{O}_3$  on the LATP SSEs.<sup>51</sup> They used different ALD cycles (*i.e.*, 25, 50, 100, 150, 200, and 250 cycles) and were able to prepare an interfacial layer on the LATP surface with various thicknesses (see Fig. 18(a–i)).

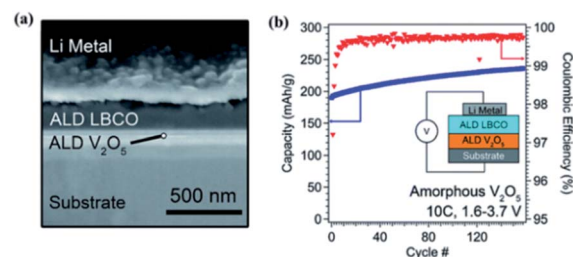


Fig. 17 (a) SEM image of the FIB cross section of the full cell stack used in electrochemical measurements and (b) plot of discharge capacity and coulombic efficiency for the cell cycled at 10C.<sup>48,49</sup>

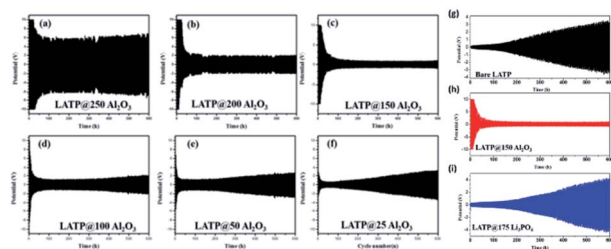


Fig. 18 Electrochemical behavior of  $\text{Al}_2\text{O}_3$ ALD coated LATP/Li symmetrical cells after (a) 250, (b) 200, (c) 150, (d) 100, (e) 50, and (f) 25 cycles at a current density of  $0.01 \text{ mA cm}^{-2}$ , where each cycle takes 2 h for lithium stripping and plating, (g) cycling behavior and voltage profile of bare LATP/Li in the 1st, 100th, 200th, and 300th cycles, (h) cycling behavior and voltage profile of LATP@150 $\text{Al}_2\text{O}_3$ /Li in the 1st, 100th, 200th, and 300th cycles, and (i) cycling behavior and voltage profile of LATP@175 $\text{Li}_3\text{PO}_4$ /Li in the 1st, 100th, 200th, and 300th cycles.<sup>51</sup>

They concluded that there is an optimum film thickness capable of improving the performance along with the stability and the reported LATP@150 $\text{Al}_2\text{O}_3$  (*i.e.*, ALD 150 cycles) sample as the best performing electrolyte compared to the other structures (ALD-treated and bare LATP).<sup>51</sup> It is important to note that the LATP@150 $\text{Al}_2\text{O}_3$  electrolyte demonstrated the lowest impedance during extended cycling and was more stable at the interface of LATP/Li anode due to the formation of a conductive layer (Li–Al–O) protecting the LATP structure.<sup>51</sup>

In a subsequent study, the same group adopt ALD to coat an interfacial layer of  $\text{Al}_2\text{O}_3$  on LATP and designed a sandwich-type multi-layer barrier and employed polyethylene oxide (PEO) to coat both sides of LATP@ALD  $\text{Al}_2\text{O}_3$ .<sup>52</sup> They analyzed the performance of sandwich-type SSEs (*i.e.*, PEO/bare-LATP/PEO (PLP) and PEO/ALD  $\text{Al}_2\text{O}_3$ –LATP/PEO (ALD-PLP)) in a cell stack assembled with a sulphur electrode.<sup>52</sup> The ALD coated PLP SSE demonstrated significant electrochemical performance (almost two time higher than that of PLP SSEs) with the initial discharge capacity reaching as high as  $1035 \text{ mA h g}^{-1}$ , which gradually reduced to  $823 \text{ mA h g}^{-1}$  at the end of 100 cycles, as shown in Fig. 19(a).<sup>52</sup> X-ray photoelectron spectroscopy (XPS) study revealed that the ALD coating prevents the reduction of Ti by polysulphides within the LATP structure (see Fig. 19(b)).<sup>52</sup> According to Fig. 19, the XPS spectra associated with the bare LATP sample included a strong Ti 1s peak related to reduced-Ti and a weak peak ascribed to  $\text{Ti}^{4+}$  at the end of cycling, whereas the XPS spectra of the ALD-LATP sample did not include these strong peaks.<sup>52</sup> This finding revealed that the ALD coating is very effective in protecting the LATP structure while preventing the reduction of Ti.<sup>52</sup> Using ALD, the introduction of an interfacial layer of  $\text{Al}_2\text{O}_3$  improves ionic conductivity, durability, and cycle performance, and reduce interfacial resistance between the electrolyte and electrode. This interfacial layer not only prevents the release of polysulfide, but also reduces the side reactions between the polysulfide and oxides within the SSE structure lessening the resistance.

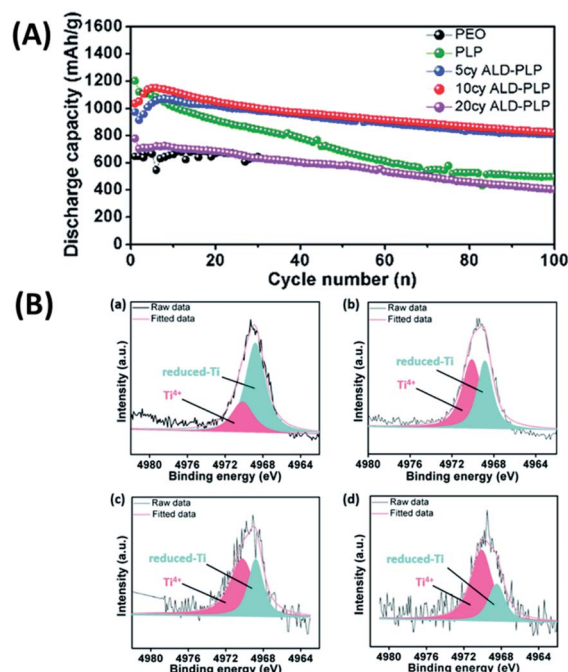


Fig. 19 (A) Cycling performance of Li–S batteries with different electrolytes, where cell cycling was performed at a current density of  $0.1\text{C}$  ( $1\text{C} = 1670 \text{ mA h g}^{-1}$ ) and  $60^\circ\text{C}$ . (B) Ti 1s XPS of (a) bare LATP, (b) 5 cycles of ALD-LATP, (c) 10 cycles of ALD-LATP and (d) 20 cycles of ALD-LATP after 100 charge/discharge cycles. All XPS studies were conducted on the LATP surface facing the sulfur cathode.<sup>52</sup>

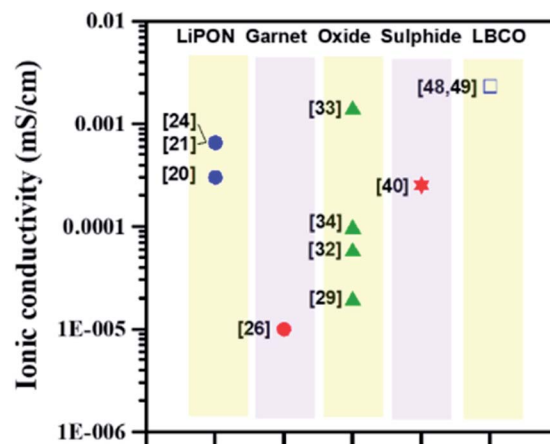


Fig. 20 Variation of ionic conductivity at room temperature with different SSEs prepared by the ALD technique.

### 3. Summary and future prospects

In this review, we have highlighted the implementation of ALD for depositing a thin and conductive interlayer at the solid-electrolyte–electrode interface for the LIBs utilizing solid state electrolytes and Li metal anodes. Different classes of SSEs including LiPON-, garnet-, oxide-, perovskite-, sulphide-, LBCO-, and NASICON-type electrolytes have been discussed and prior pioneering ALD studies conducted for depositing conformal and conductive barriers for each category of SSEs have been





summarized. In particular, we have focused on the interface between the electrode and solid electrolyte since the utilization of SSEs in direct contact with Li metal commonly results in the formation of an unstable solid-electrolyte interface. Thus, it is critical to protect the SSE structure for designing high energy density LIBs utilizing Li anodes.

ALD can be implemented for depositing an interfacial layer with desired attributes (high durability and ionic conductivity) capable of protecting the SSE against Li anodes. In Fig. 20, we have compared the variation in ionic conductivity for different classes of SSEs. Given the bulk ionic conductivity measured for different SSEs ( $\sim 10^{-8}$  to  $10^{-4}$  S cm $^{-1}$ , see Table 1), much work is still needed for designing high-conductivity solid electrolytes (target:  $\sim 10^{-3}$  to  $10^{-2}$  S cm $^{-1}$ ) for next-generation LIBs. To enable high rate capability, a new design of SSEs (ionic conductivity:  $>10^{-3}$  S cm $^{-1}$ ) with high durability and mechanical stability is required. We believe that the ALD technique can be adopted for synthesizing new types of SSEs as well as depositing a conductive thin interfacial layer with desired characteristics.

Considering the unique properties of the ALD method, this technique can be used for synthesizing an emerging class of SSEs including lithium super ionic conductors (LISICONs). For example,  $\text{Li}_x\text{Al}_y\text{S}_z$  ( $6.42 \times 10^{-4}$  S cm $^{-1}$ ) and  $\text{Li}_{1.4}\text{Al}_{0.4}\text{Ti}_{1.6}(\text{PO}_4)_3$  ( $2.94 \times 10^{-4}$  S cm $^{-1}$ ) are promising SSEs with high ionic conductivity and remarkable durability. To this end, selecting appropriate precursors and precisely controlling the ALD operating conditions (e.g., temperature, pressure, and subcycle sequence during a full ALD cycle) are critical. As summarized in Tables 1–3, only a limited number of precursors have been reported in prior ALD coating of SSEs. One interesting and relatively unexplored area is to elaborate on the doping process *via* ALD. To accomplish the desired doping procedure, the proportionalities of dopants must be finely tuned to finely tune the morphology and crystalline phase of SSE films and subsequently achieve high ionic conductivity. In addition, several dopant precursors need to be employed to fully explore the ALD doping chemistry. Indeed, designing an ALD system must be focused on enabling a precise control over the microstructure of the solid electrolytes. The SSEs prepared through ALD usually possess an amorphous or a mixture of amorphous and crystalline structures. Thus, a post-annealing treatment must be conducted for achieving desired microstructures.

Finally, the implementation of ALD for depositing thin and conductive films on SSEs should not be limited for lithium ion battery applications. Indeed, the ALD technique can be tuned for coating conductive interlayers with desired attributes within solid-electrolyte–electrode interfaces for other electrochemical devices (e.g., Li–air, Li–S, Li metal, and hybrid flow batteries) utilizing Li metal anodes and solid-state electrolytes. Although the details provided in this work were solely focused on batch-type ALD systems, the insights gained through this review can be applied for designing roll-to-roll ALD apparatus enabling continuous and large-scale production.

## Conflicts of interest

There are no conflicts to declare.

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